

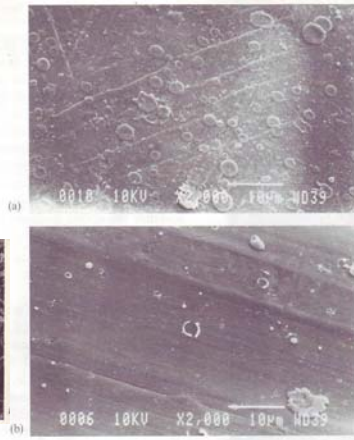
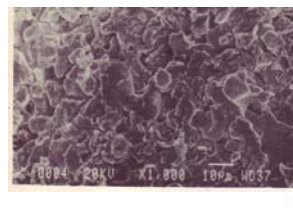
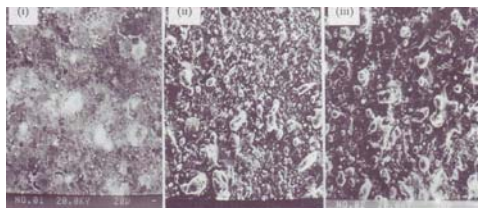
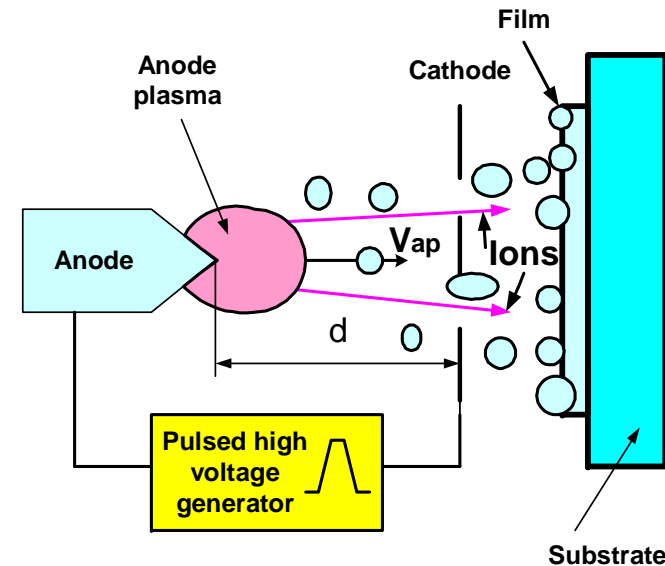
Deposition of Films & Coatings

The physical methods deposition of films and coatings based on magnetron sputtering and pulsed ion diode present the improved and novel technique with large opportunities for industry and science.

Applications:

1. Deposition of films and coatings with high adhesion to substrate.
2. Deposition of films on the cold substrates.
3. Deposition of films on the polymer and paper.
4. Deposition of films with stable stoichiometric,
5. Deposition of high temperature films and coatings.
6. Surface modification of deposited films

Pulsed ion diode for deposition of films & coatings



Magnetron sputtering systems